







100

50.0

3.817 x10²²

3.00

2.00

-1.00

0.000



A_RD_25: Continued Effort Towards Ultimate Performance for Accelerator Cavities



2025 FKPPN - FJPPN joint Workshop, Nantes 14-16 May 2025

COMPOSITION OF TEAMS

ID1:	Title: A_RD_25 Continued effort towards ultimate performance for accelerator cavities					
	French Group			Japanese Group		
	Name	title	lab. ²	name	title	lab. ²
PIs: Members [:]	(Family name, First name)			(Family name, First name)		
	Yasmine KALBOUSSI	Dr.	Irfu	Takayuki KUBO	Dr.	KEK
	e-mail:	1		e-mail:	1	
	yasmine.kalboussi@cea.fr			kubotaka@kek.jp		
	Claire ANTOINE (Emeritus)	Dr.	Irfu	Ryo KATAYAMA	Dr.	KEK
	Thomas PROSLIER	Dr.	ltfu	Takeyoshi GOTO	Dr.	KEK
	Enrico CENNI	Dr.	lrfu	Hayato ITO	Dr.	KEK
	Théo DEJOB	Dr.	ltfu	Yasuhiro FUWA	Dr.	KEK
	Ivana CURCI		ltfu	Takayuki SAEKI	Dr.	KEK
	Grégoire JULLIEN		Irfu	Yoshihisa IWASHITA	Dr.	Osaka Univ.
	Fabien EOZENOU		Irfu			

FY 2024 Exchange program:

- KEK side: Visit of R. KATAYAMA in September 2024
- Irfu side: Visit of C. ANTOINE & G. JULLIEN in January 2025

FY 2025 Exchange plans:

- KEK side: Visit of Y. FUWA and/or T. GOTO in September 2025
- Irfu side: Visiting candidate under discussion

Continued Effort Towards Ultimate Performance for Accelerator Cavities

Japan Part

- **1. Progress in theory**
- 2. Experimental effort for TF
- 3. 3GHz cavity
- 4. Vertical & HF free EP

T. Kubo R. Katayama Y. Fuwa T. Goto

Electromagnetic response to a weak rf superposed on a dc bias: tackle the problem head-on using the Keldysh-Eilenberger theory of nonequilibrium superconductivity

This long-standing and tough problem—belong to nonequilibrium superconductivity and relevant to many superconducting devices, including the Q-slope in SRF cavities—had not been solved correctly.



Plan of 2025

Apply the Keldysh-Eilenberger (or Keldysh-Usadel) theory of nonequilibrium superconductivity to superconducting devices—including SRF cavities—to gain deeper insights beyond what has been achieved so far.

Some new findings have already been obtained.

In dirty superconductors under combined dc and ac fields, there exists a frequency range where the superconducting Higgs mode drives the imaginary part of the conductivity (i.e., the superfluid density) negative, leading to instability.



Continued Effort Towards Ultimate Performance for Accelerator Cavities

Japan Part

- **1. Progress in theory**
- 2. Experimental effort for TF
- 3. 3GHz cavity
- 4. Vertical & HF free EP

T. Kubo R. Katayama Y. Fuwa T. Goto

Clean-booth for Sputtering System

View of 2024.03



View of 2025.05



- A DC magnetron sputtering apparatus was installed on March 19, 2024 at KEK COI building.
- This Fiscal year, we constructed a clean booth surrounding the sputtering system.
- We evaluated the cleanliness of the clean booth by measuring the number of particles, which was found to be 20 particles per 28.3 liters of air.

Simulation Study



- Sputtering simulation was performed to understand what film formation condition is optimal especially for Nb3Sn coating method.
- We used the software modules developed by PEGASAS software inc., in order to perform the sputtering simulation.
- Current status of simulation study:
 - Ar+ generation rate, number of superparticles of e- and Ar+, DC magnetron sputtering can be simulated.
 - Uniformity of films looks not ideal.
- The simulation study is ongoing for optimization.

Flat samples preparations









- We have prepared more than 100 silicon substrates for the thin-film study.
- The φ20 mm silicon substrates were cut from a φ300 mm silicon wafer coated with a protective resist layer.
- At present, we have successfully performed DC magnetron sputtering on these substrates.

Plan for 2025

- We are creating Nb3Sn and AIN thin films on silicon substrates and evaluating the superconducting properties of these samples.
- More detailed sputtering simulations will be conducted.
- Sputtering will also be applied to a 3 GHz coupon cavity and a 3 GHz cavity.

Continued Effort Towards Ultimate Performance for Accelerator Cavities

Japan Part

- 1. Progress in Theory
- 2. Experimental effort for TF
- 3. 3GHz cavity
- 4. Vertical & HF free EP

T. Kubo R. Katayama Y. Fuwa T. Goto

3GHz Cavity preparation

Previous treatment applied on cavity #1 (see 2024 Meeting): BCP treatment

Nb-flange with pure-AL hexagon seal, 158 µm BCP, no-EP, no-anneal, with 120degreeC baking







f=2.992172GHz at 2K



Cavity observation



Inner surface 85 degree equator close to the heating point 90degree. 12 No defect found.

EP processing for 3GHz elliptical cavities (FY2024) In FY2024, EP (electropolishing) process for 3GHz single-cell elliptical cavity was performed.



For EP process, a vertical EP setup dedicated to 3 GHz cavities was used.

EP treatment was performed in two stages:

- EP1 (100 µm) with the cavity temperature below 50°C (increased removal rate)
- (annealing at 900°C was performed for 3 hours)
- EP2 (30 μ m) with the cavity temperature below 20°C



Inner surface after EP (left: equator region, right: iris region)

Vertical test of 3GHz elliptical cavities (FY2025)

Vertical test (VT) will be performed to measure RF performance of 3 GHz cavities at KEK-STF.



Preliminary test result of VT in April 2025 For a 3GHz cavity after EP2 process $-E_{acc} \sim 22 \text{ MV/m}$ $-Q_0 > 1 \times 10^9 \quad (@ 2K)$

Established measurement system for 3 GHz cavities will be tuned in order to measure the performance of cavities with various treatments in the future: thin-film coating, mid-T baking, etc...

Continued Effort Towards Ultimate Performance for Accelerator Cavities

Japan Part

- 1. Progress in Theory
- 2. Experimental effort for TF
- 3. 3GHz cavity
- 4. Vertical & HF free EP

T. Kubo R. Katayama Y. Fuwa T. Goto

Development of HF free EP of Nb with organic solvents (Report FY2024)

- Hydrofluoric acid (+ sulfuric acid) is very dangerous as gas and liquid. >> high cost of EP process
- In the EP reaction, hydrogen atoms derived from water molecules in the electrolyte are absorbed into Nb. >> Nb-H is formed in Nb, and the SRF performance of the cavity is very limited (especially, E_{acc}). >> These problems can be solved by developing an EP process that uses organic solvents containing less water

molecules in the electrolyte.

2023: sample area 1 cm² - 1 M NH₄F in ethylene glycol









- For a larger sample area, the reaction conditions were optimized.
- The conditions under which the difference between the front and back of the substrate becomes small were investigated.

Development of HF free EP of Nb with organic solvents (Plan FY2025)

- 1 M NH₄F in ethylene glycol 2024: ~10 cm²



2025: ~1000 cm² (assuming EP treatment of cavity)

- Large samples (~1000 cm²) will be tested.
- The effect of small cathode area relative to anode will be examined

-

The effect of increasing the distance between electrodes will be examined.

- For a larger sample area, the reaction conditions will be more optimized.
- In 2025, the suitable conditions for larger sample area (~1000 cm²) will be investigated.

Continued Effort Towards Ultimate Performance for Accelerator Cavities

French Part

- 1. Vertical electropolishing
- 2. Multilayers

F. Eozénou Y. Kalboussi

ELECTROLYTE INVESTIGATION

- HF concentration 0.5% vs 3% for standard EP process
- Effect of depleted HF concentration on performance?
- Thicker oxyde might act as a barrier for Hydrogen?

Benefits of decreased HF concentration:

- Toxicity lowered compared to standard mixture (skin contact H310 Vs H311)
- No storage limitation constraint at Saclay

- A new acid will be tested with theoretical HF concentration divided by 2: 'SF10-1'
- The acid has been purchased and received
- The efficiency of the acid will be tested on single cell 1300MHz cavity



Blueish color obtained after VEP on ESS 704 MHz single cell cavity

INVESTIGATION WITH 'SF 10-1' ON SAMPLES

Investigation on samples: I(V) plot





- > A clear 'plateau' is noticed for a wide range of potentials
- Sudden Intesity rise for U>70 V
- A dedicated 500V power supply will be used to investigate U>70V. Similar to Plasma ElectroPolishing ?



NEXT STEP: APPLICATION ON SINGLE CELL CAV

- The cavity RI01 has been purchased
- Test with 'standard' recipe for reference test
- \geq ~240 µm bulk EP (0.15µm/min)



RESULTATS RIO1 APRES EPV BAIN STANDARD @2K



RI01 tested twice with standard recipe: Field emission

I(t) EP RI01 19V 9.5°C 5L/min 50 45 40 35 30 25 20 15 10 5 0 1000 200 400 600 800 temps (s)

Typical current oscillations during standard VEP



Strong degassing during HT after standard recipe

- > Performance of RI01 limited by Field Emission (presence of a large defect at the surface?)
- Addition 50 µm have been removed with standard recipe/parameters prior to VT

21

Continued Effort Towards Ultimate Performance for Accelerator Cavities

French Part

- 1. Vertical electropolishing
- 2. Multilayers

F. Eozénou Y. Kalboussi

The lab – Deposition Lab







- Two ALD deposition systems:
- Research scale: small samples (Φ = 5 cm , L = 40 cm) New chemistries
- Development scale: Macroscopic objects (Φ = 49 cm , L = 110 cm).
 1.3, 0.7 GHz cavities
- Future:
- HIPIMS deposition system for A15 on 1.3 GHz cavities and large coupons.
- Thematic:
- Superconductors (cavities, QuBits), multipacting, Corrosion, Filtration...



The Lab - Characterization







- Tunneling spectroscopy (Superconducting properties: gap, local Tc, Mapping – 1,5 K – 1x1 cm²)
- Transport measurements (Tc, RRR)
- Projects:
- Collaboration USA (thesis, measurements)
- Collaboration with CERN (Nb₃Sn/Cu...)
- Research area:
- Qubits, cavities, ALD...



Multilayers





- A theoretical approach proposed by A. Gurevich (2006) to improve RF cavities through depositing a superconducting multilayer to screen the magnetic field.
- The thickness of the superconductor must be lower than its penetration depth.
- The superconducting layer must have higher T_c than Nb.

Multilayers: NbTiN



To enhance the superconducting performances of NbTiN films, several thermal treatments have been tested. The best results on Nb coated samples were obtained with:

- ➤ A first ramp of 6 °C/ minute up to 800°C
- A second ramp of 18°C/minute up to 900°C

NbTiN (45 nm) – AIN (10 nm) – Niobium NbTiN (45 nm) – AIN (10 nm) – Sapphire Plateforme MPBT 2,0×10⁻⁴ covered 8 · Bare 7 · 0,0



T_c is similar on Niobium and Sapphire substrate.



ALD on SRF cavities and multilayers

> The Niobium ellipsoid was coated and annealed with the optimized NbTiN-AIN bilayer recipe.



- Enhancement of first penetration field demonstrated.
- Thicker layer (~ 200 nm) to determine ξ and the predicted optimal thickness

NbTiN-AIN Multilayer on 1,3 GHz cavity

- The Niobium cavity was coated with the optimized AIN- NbTiN bilayer recipe



- Coating had a bright golden and uniform colour.
- The cavity was annealed @ 900°C.
- Vacuum degradation during the annealing step on the first test.
- (P>10⁻⁵ mbar)
- Observed delamination in the beam tubes after annealing.

Delamination studies

- Leak detected and fixed.

- Upscaling of the samples with tubes and curve plate



- Presence of film confirmed by XRD, EDS, MEB
- No delamination observed



- Tc ~ 14.5 15 K (42 nm)
- New multilayer diffusion barrier.

PURSUE THE EFFORT TOWARDS ULTIMATE GRADIENTS AND QUALITY FACTORS FOR SRF CAVITIES.

	<u>CEA Saclay</u>	KEK
VEP	 VEP with a depleted HF concentration (<0.5%) with Ninja cathode: ongoing Single-cell 1300MHz cavities prior to ALD deposition 704MHz activities 	New VEP facility for 1.3GHz 9-cell cavity, in addition to HEP facility. The Ninja cathode dedicated for the VEP process for cavity Hydrofluoric acid-free EP process Plasma electrolytic polishing (PEP)
Thin- film	A multilayer Nb/AlN/NbTiN ALD layers deposition on 3000MHz Cu and Nb cavities.	AlN-NbN thin-film: coupon analysis AlN-NbN thin-film grown on single-cell 3000MHz Nb cavities. The cavities will be tested at 4K and 2K. Theoretical study of multilayer structure.

THANK YOU FOR YOUR ATTENTION